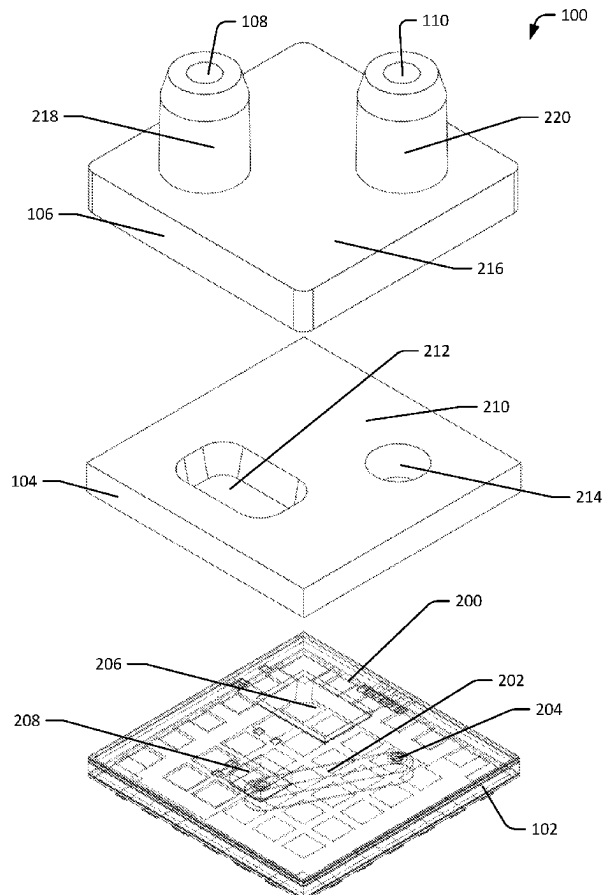




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(19) **United States**(12) **Patent Application Publication**
MEHROTRA et al.(10) **Pub. No.: US 2025/0264367 A1**(43) **Pub. Date: Aug. 21, 2025**(54) **LAMINATE SUBSTRATE-BASED
DIFFERENTIAL PRESSURE SENSOR
PACKAGE COMBINING AIR CAVITY
CHANNEL SUBSTRATE, OVERMOLD, AND
LID WITH TWO CHIMNEYS**(71) Applicants: **Renesas Electronics America Inc.**,
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CPC **G01L 13/025** (2013.01); **G01L 19/0038**
(2013.01); **G01L 19/0069** (2013.01)(57) **ABSTRACT**

The sensor device includes a substrate having upper and lower surfaces with a channel formed therebetween. First and second port holes are formed through the upper surface to the channel. The sensor device also includes an application-specific integrated circuit (ASIC) die mounted on the upper surface so as not to cover the first and second port holes. The sensor device further includes an overmolding formed on the upper surface that is molded over the ASIC die and forms first and second cavities surrounding the first and second port holes, respectively. The sensor device also includes a transducer electrically connected with the ASIC die and mounted within the first cavity on the upper surface so as to cover the first port hole. The sensor device further includes a lid attached to the overmolding having first and second chimneys.



100

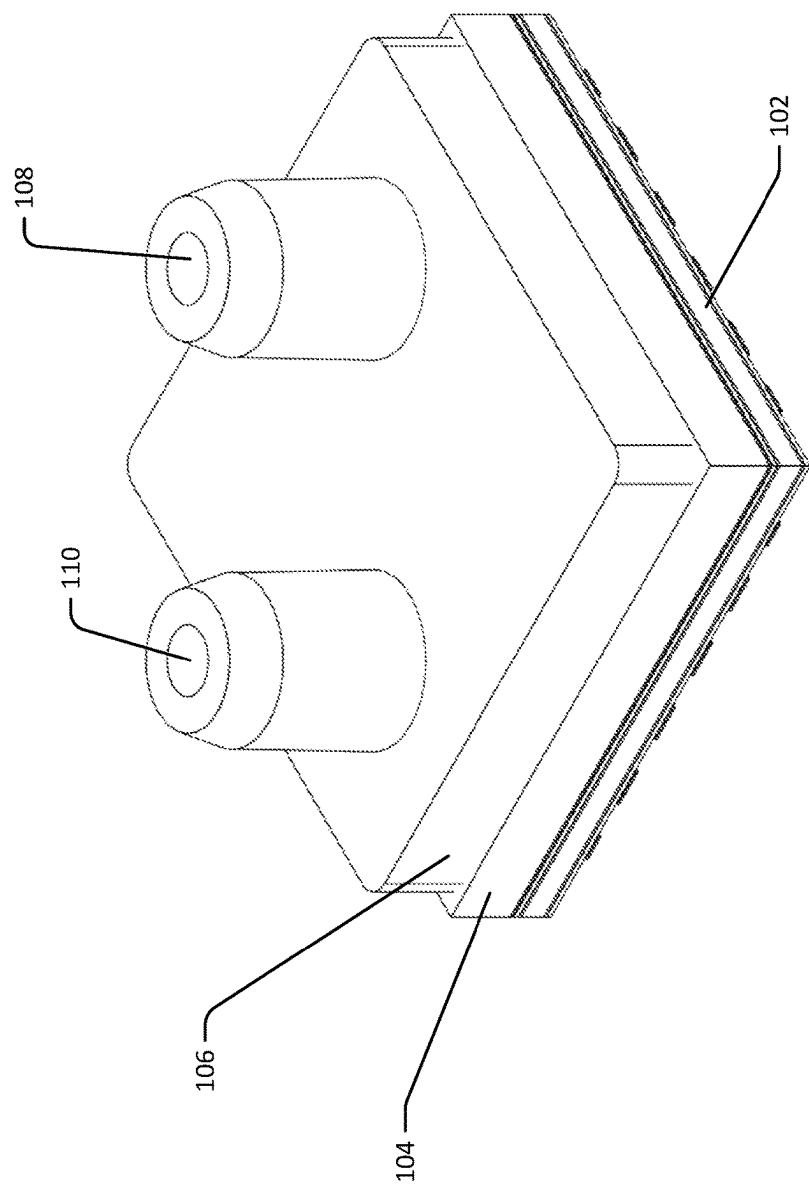


FIG. 1

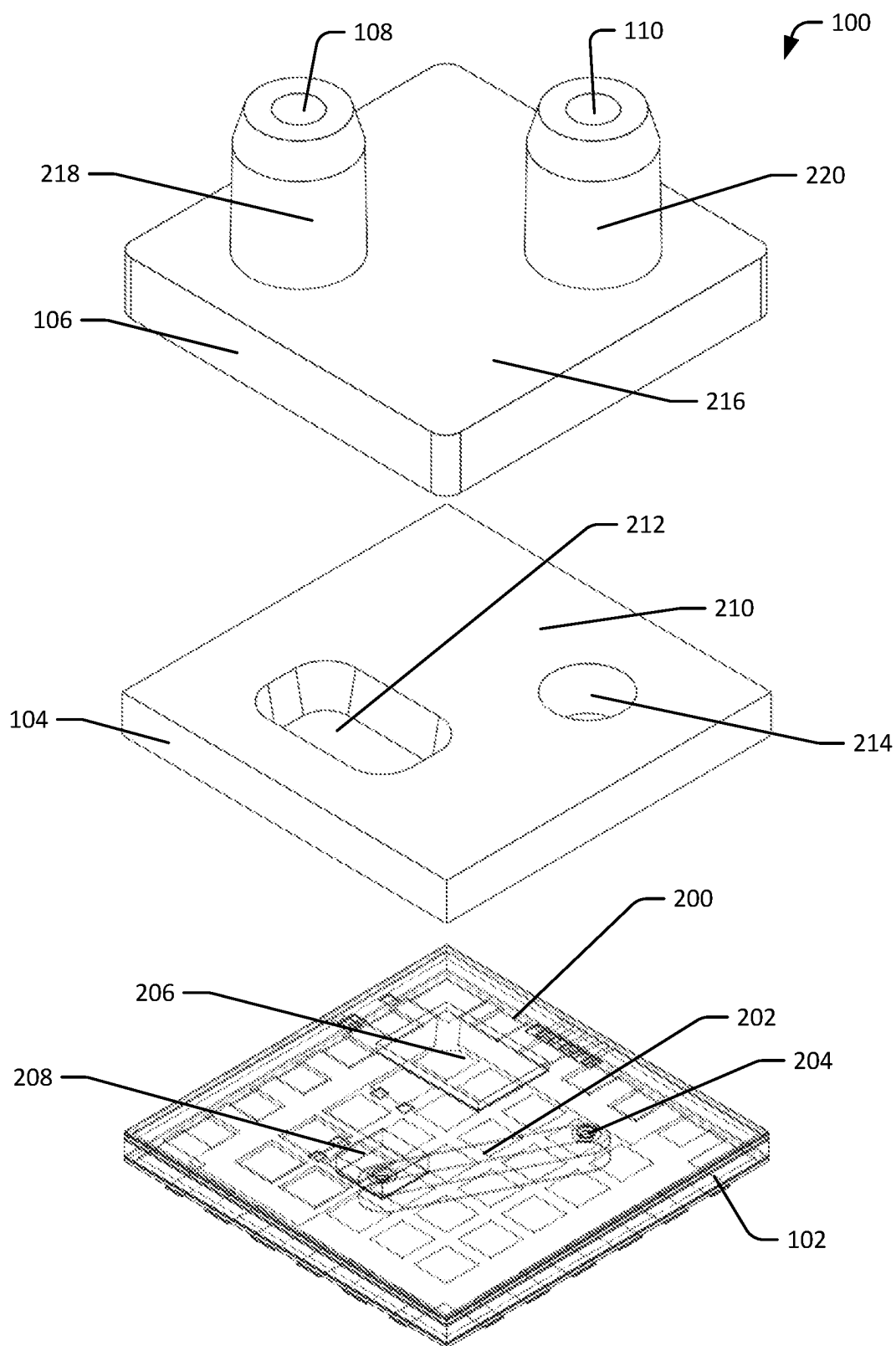


FIG. 2

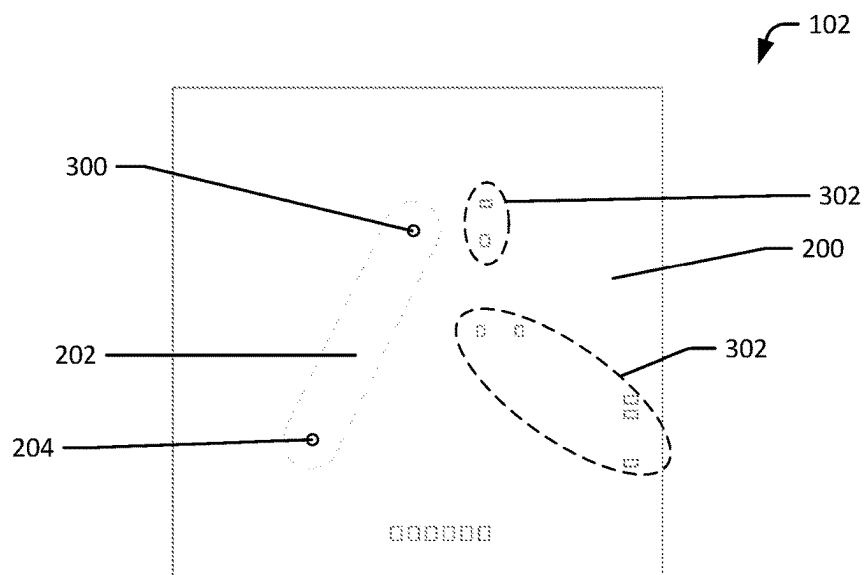


FIG. 3

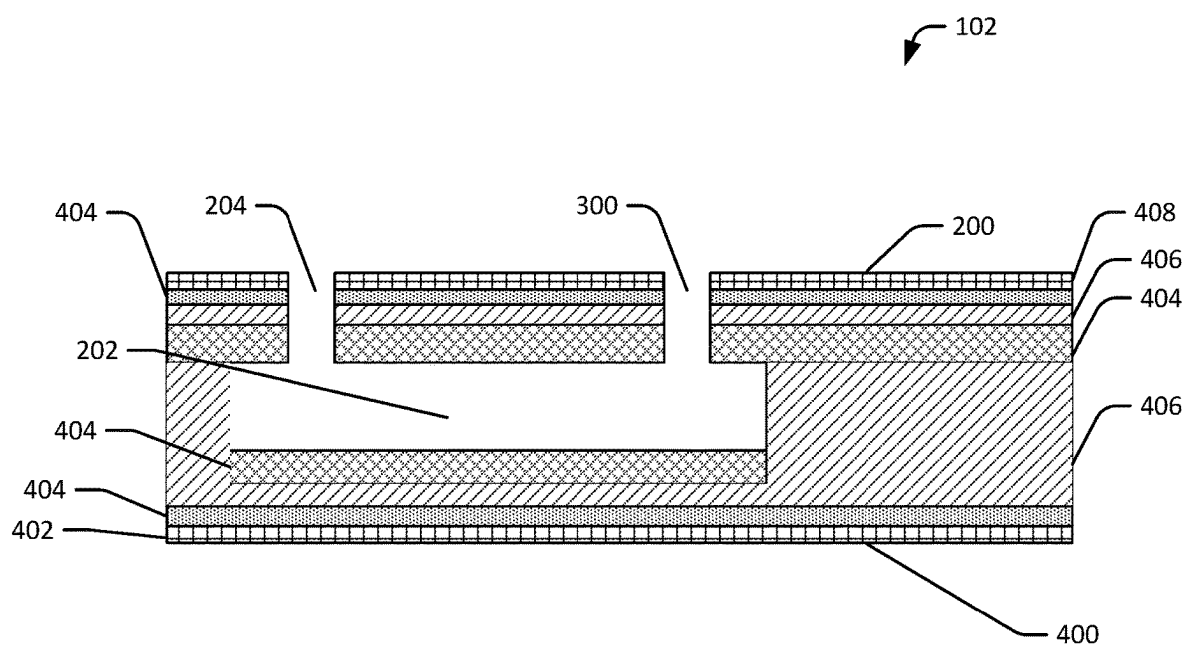


FIG. 4

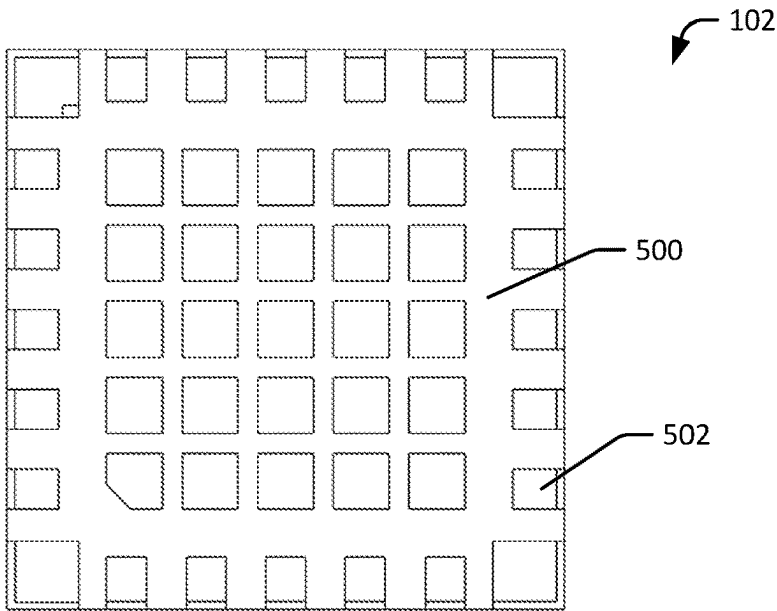


FIG. 5

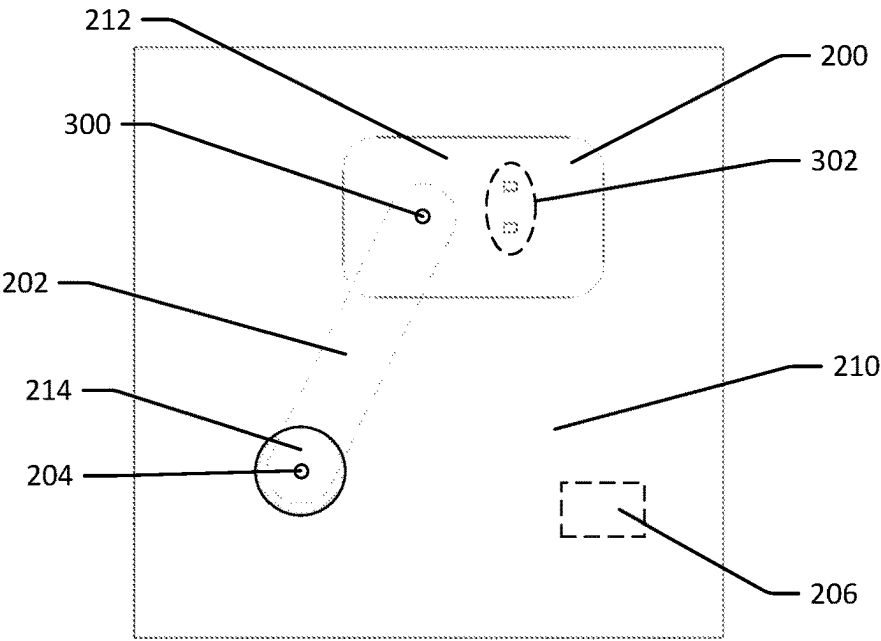


FIG. 6

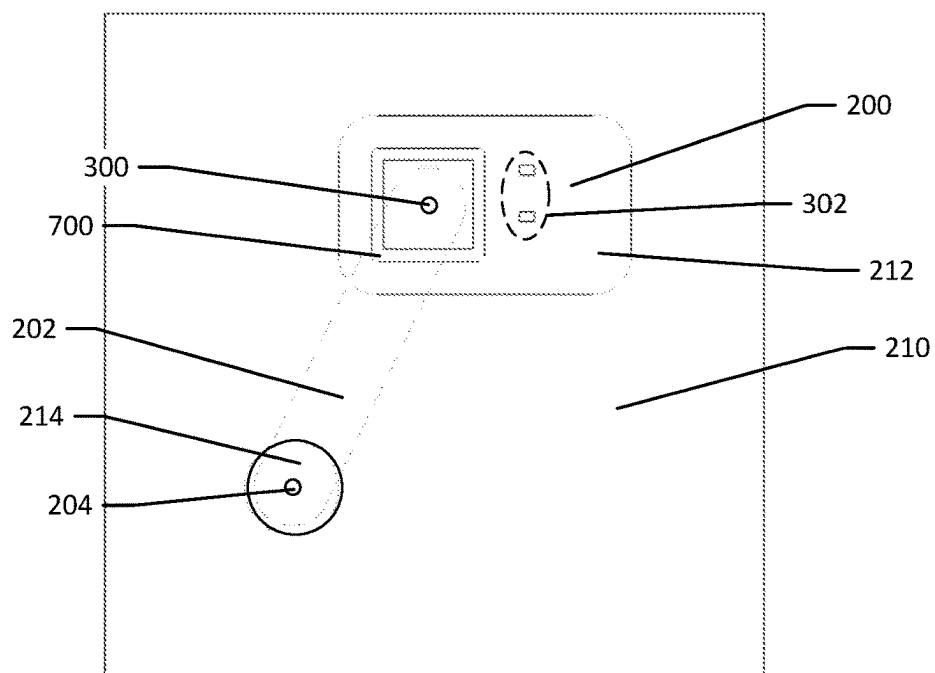


FIG. 7

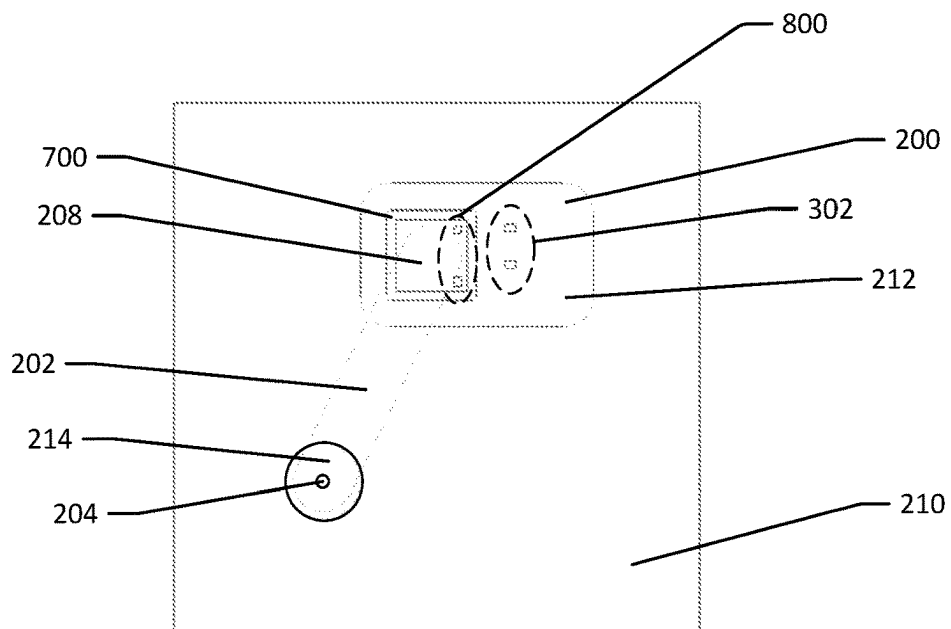


FIG. 8

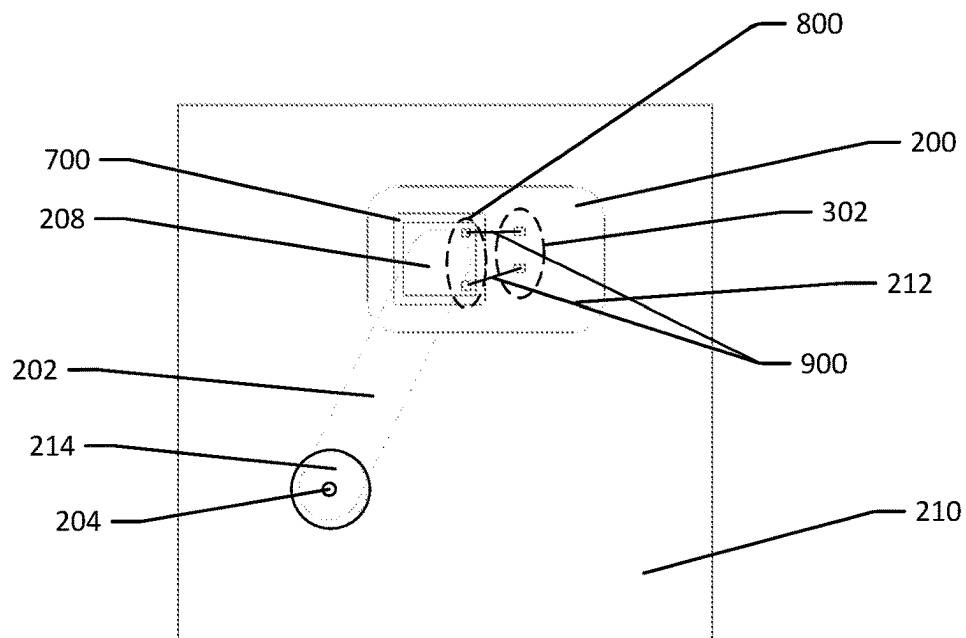


FIG. 9

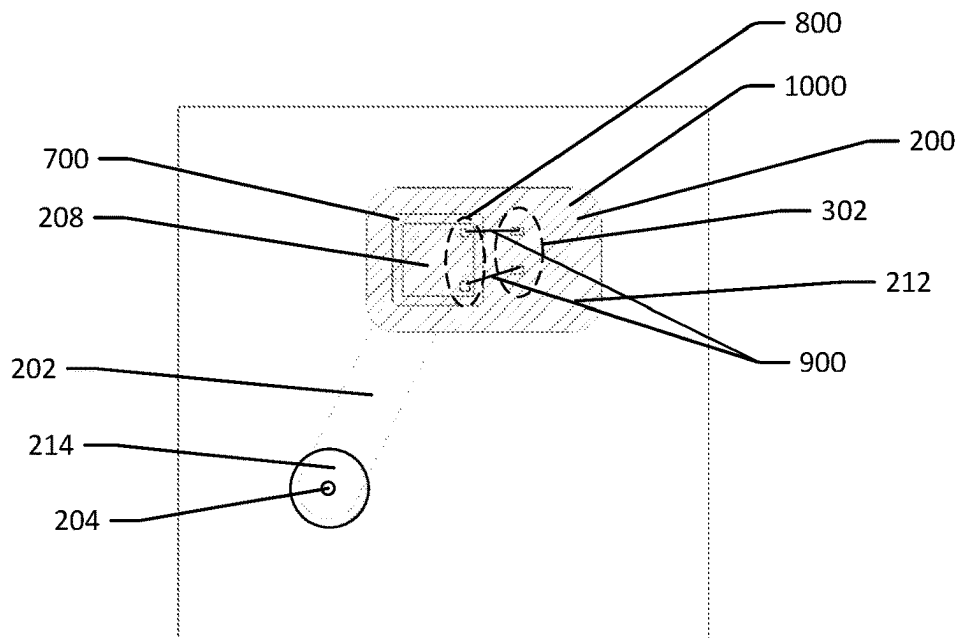


FIG. 10

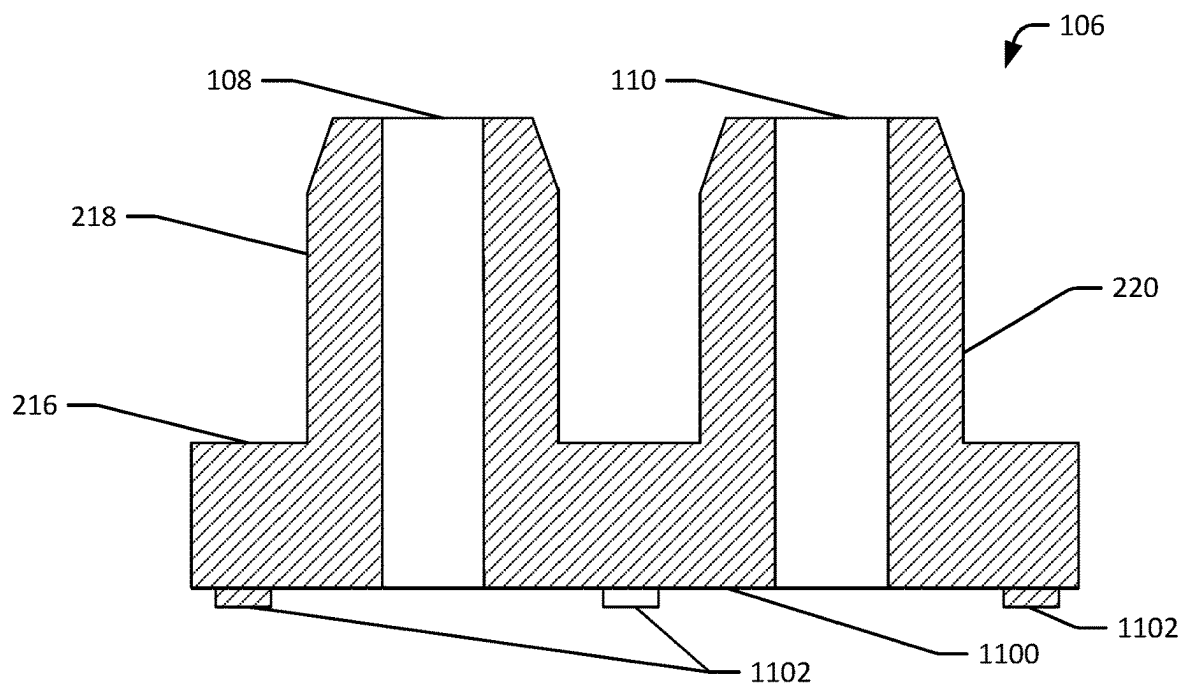


FIG. 11

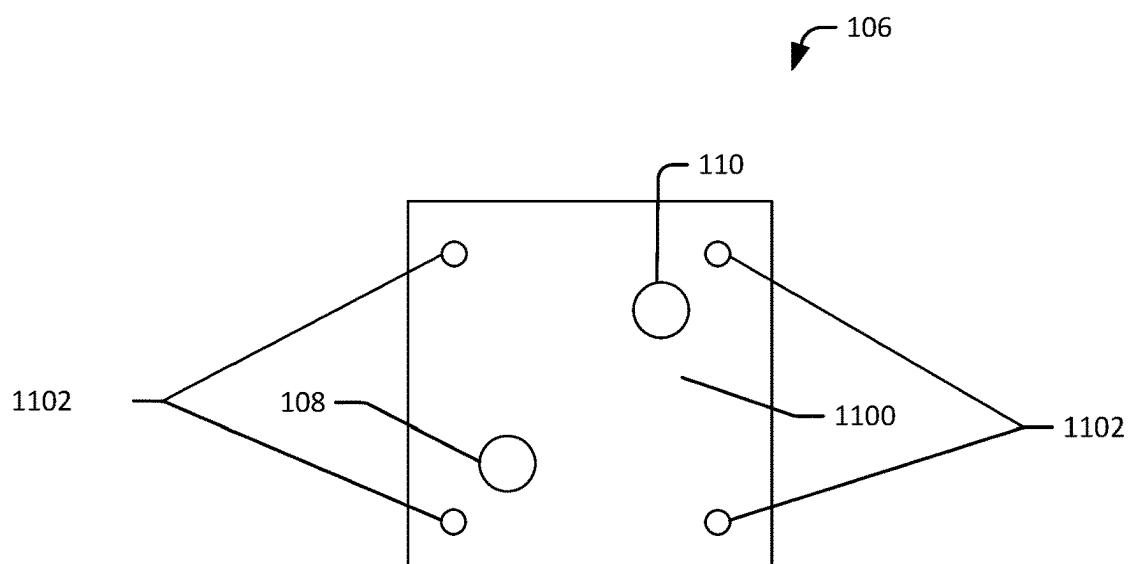


FIG. 12

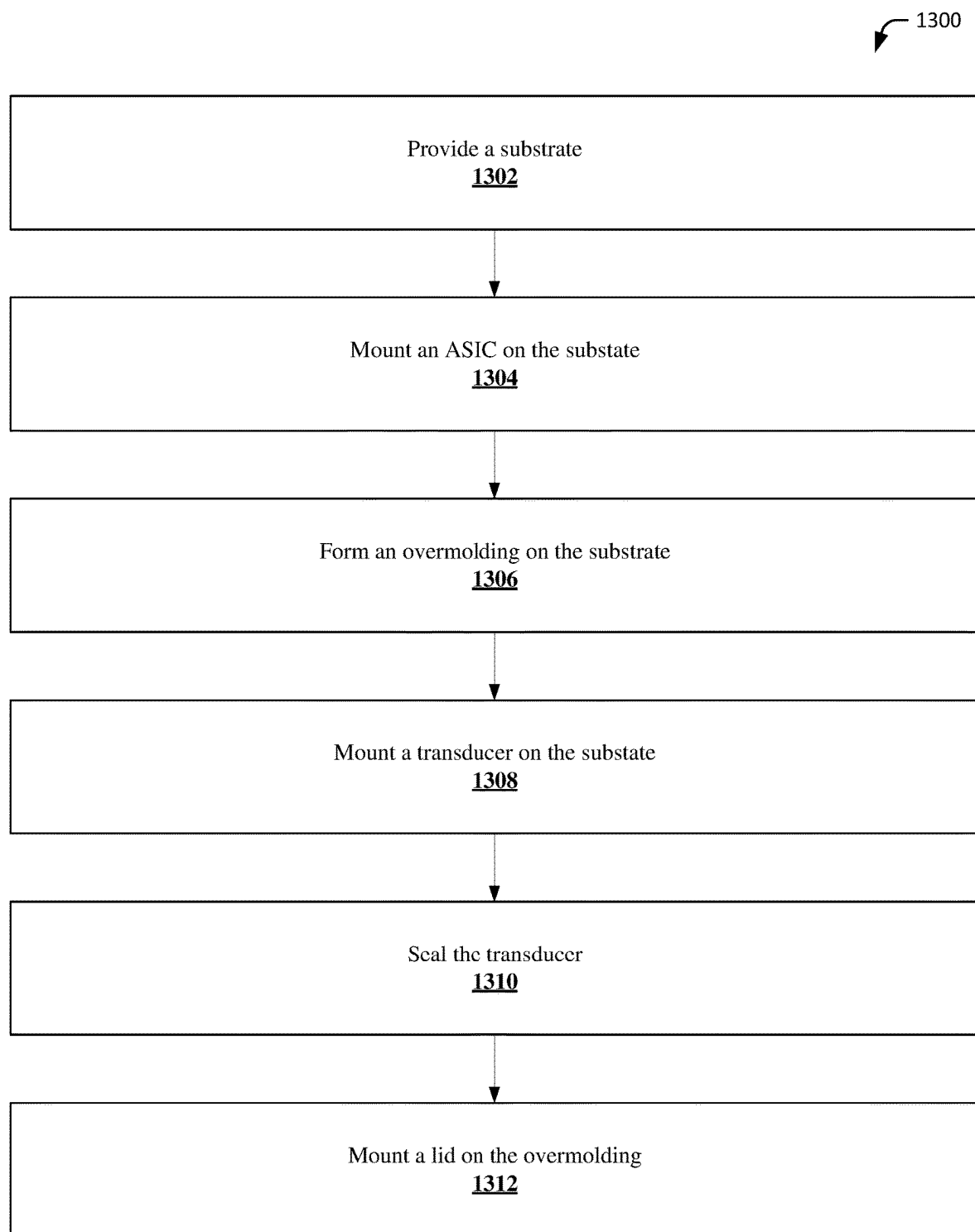


FIG. 13

**LAMINATE SUBSTRATE-BASED
DIFFERENTIAL PRESSURE SENSOR
PACKAGE COMBINING AIR CAVITY
CHANNEL SUBSTRATE, OVERMOLD, AND
LID WITH TWO CHIMNEYS**

BACKGROUND OF THE SPECIFICATION

[0001] The present disclosure relates to differential pressure sensors (DPS).

[0002] DPS are a type of pressure sensor device that measures differences in pressure between two points in a system. This allows for more accurate readings of fluid (liquid or gas) systems, where changes in pressure can be critical. By measuring pressures at different locations, these sensors enable the detection of flow rates, filter conditions, and other variables that influence system performance. Packaging of DPS can be very important. For example, overall sizes of DPS and implementations (e.g., accessing both sides of a membrane) can be difficult in small applications.

SUMMARY

[0003] A sensor device is described herein. The sensor device includes a substrate having a substrate upper surface and a substrate lower surface opposite the substrate upper surface. The substrate forms a channel between the substrate upper surface and the substrate lower surface and forms first and second port holes through the substrate upper surface to the channel. The sensor device also includes an application-specific integrated circuit (ASIC) die mounted on the substrate upper surface so as not to cover the first port hole and the second port hole. The sensor device further includes an overmolding formed on the substrate upper surface that is molded over the ASIC die and forms first and second cavities surrounding the first and second port holes, respectively. The sensor device also includes a transducer electrically connected with the ASIC die and mounted within the first cavity on the substrate upper surface so as to cover the first port hole. The sensor device further includes a lid attached to the overmolding and having first and second chimneys.

[0004] The foregoing summary is illustrative only and is not intended to be in any way limiting. In addition to the illustrative aspects, embodiments, and features described above, further aspects, embodiments, and features will become apparent by reference to the drawings and the following detailed description. In the drawings, like reference numbers indicate identical or functionally similar elements.

BRIEF DESCRIPTION OF THE DRAWINGS

[0005] FIG. 1 illustrates an example of a laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

[0006] FIG. 2 illustrates an exploded view of the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

[0007] FIG. 3 illustrates a top plan view of a substrate of the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

[0008] FIG. 4 illustrates a section view through a channel of the substrate of the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

[0009] FIG. 5 illustrates a bottom plan view of the substrate of the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

[0010] FIGS. 6-10 illustrate top plan views of the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys as various manufacturing steps are applied.

[0011] FIG. 11 illustrates a section view through chimneys of a lid of the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

[0012] FIG. 12 illustrates a bottom plan view of the lid of the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

[0013] FIG. 13 illustrates an example method of manufacturing the laminate substrate-based differential pressure sensor package combining an air cavity channel substrate, an overmold, and a lid with two chimneys.

DETAILED DESCRIPTION

[0014] FIG. 1 illustrates an example of a differential pressure sensor 100. The differential pressure sensor 100 contains a substrate 102, an overmolding 104, and a lid 106. The lid 106 contains a first port 108 and a second port 110. The first port 108 and the second port 110 may be configured to accept tubing, piping, or directly connect to an area of interest. The differential pressure sensor 100 is configured to measure a pressure differential between the first port 108 and the second port 110. The differential pressure sensor 100 may have a rectangular footprint and have a size on the order of 7 mm long by 7 mm wide by 5 mm tall. The differential pressure sensor 100 may be configured to be disposed in a variety of environments ranging from -40C to 85C. Furthermore, the differential pressure sensor 100 may be configured to withstand at least 5 bar of differential pressure.

[0015] FIG. 2 illustrates an exploded view of the differential pressure sensor 100. The substrate 102 contains a substrate upper surface 200. Formed between the substrate upper surface 200 and a substrate lower surface (not shown), is a channel 202. Formed through the substrate upper surface 200 to the channel 202 is a first port hole (not shown) and a second port hole 204. The first port hole and the second port hole 204 are formed on opposite ends of the channel 202. The substrate 102 may be a four-layer structure (as discussed further below) with an overall thickness around 600 μm . The channel 202 may have a depth around 360 μm .

[0016] The channel 202 may be straight along a longitudinal axis with a rectangular cross section. A length of the channel 202 may be configured to mitigate condensation forming within the channel 202. Furthermore, the longitudinal axis of the channel 202 may be non-parallel to sides of the differential pressure sensor 100. In other words, as illustrated, the channel 202 may traverse diagonally across the substrate 102.

[0017] Attached to the substrate upper surface 200 are an ASIC die 206 and a transducer 208. The ASIC die 206 may be a semiconductor device and/or comprise a complemen-

tary metal oxide semiconductor (CMOS). The ASIC die 206 is configured to receive a voltage (or other electrical property) from the transducer 208 and communicate the voltage (or other electrical property) or a differential pressure to an external device.

[0018] The transducer 208 is communicatively coupled with the ASIC die 206. The transducer 208 may be a micro-electromechanical system (MEMS) with a membrane configured to affect a capacitance of the transducer 208 in response to a difference in pressure between the sides of the membrane. Other differential pressure sensing devices may be used without departing from the scope of this disclosure. For example, the transducer 208 may be piezoresistive, optical fiber, resonant, or piezoelectric. Regardless of how it is configured, the transducer 208 is configured to output an electrical property (e.g., voltage) that varies according to the differential pressure.

[0019] The transducer 208 is disposed on top of the first port hole in the substrate. Doing so allows a pressure from within the channel 202 to be communicated to one side of the transducer 208. Accordingly, a pressure reaching the second port hole 204 is communicated via the channel 202 to the first port hole and, thus, one side of the transducer 208.

[0020] Formed on top of the substrate 102 (e.g., on the substrate upper surface 200) is the overmolding 104 having an overmolding upper surface 210. The overmolding 104 is configured to encapsulate the ASIC die 206 while forming a first cavity 212 around the transducer 208 and a second cavity 214 around the second port hole 204. The first cavity 212 and the second cavity 214 are formed through the overmolding 104 (e.g., from the overmolding upper surface 210 to an overmolding lower surface (not shown)). The first cavity 212 may be formed such that, when the lid 106 is installed, the first port 108 is not directly above the transducer 208. In other words, the first port 108 may be offset from a top of the transducer 208. Doing so may help with environmental impact on the transducer 208 (e.g., anything falling through the port 108 will not land on the transducer 208). The shapes, sizes, and/or locations of the first cavity 212 and the second cavity 214 may vary without departing from the scope of this disclosure.

[0021] Attached to the overmolding upper surface 210 is the lid 106. The lid 106 may be formed of a plastic (e.g., a liquid-crystal polymer). The lid 106 has a lid upper surface 216 that is opposite a lid lower surface (not shown) that is attached to the overmolding upper surface 210. Protruding from the lid upper surface 216 is a first chimney 218 and a second chimney 220. The first chimney 218 and the second chimney 220 may be generally cylindrical and coaxial with the first port 108 and the second port 110, respectively. It should be noted that the first port 108 is aligned with the first cavity 212 and the second port 110 is aligned with the second cavity 214. Accordingly, the first port 108 communicates a first pressure to a top side of the transducer 208 and the second port 110 communicates a second pressure to a bottom side of the transducer via the second port hole 204, the channel 202, and the first port hole.

[0022] FIG. 3 illustrates a top plan view of the substrate 102 prior to having the ASIC die 206 or the transducer 208 installed thereon. As discussed above, the substrate 102 contains the channel 202, the second port hole 204, and the first port hole 300. Disposed on the substrate upper surface 200 are one or more transducer bond pads 302 and one or more ASIC die bond pads 304. The transducer bond pads

302 are configured to communicatively couple the transducer 208 to the ASIC die 206. The ASIC die bond pads 304 are configured to communicatively couple the ASIC die 206 to the transducer 208 and to couple the ASIC die 206 to one or more substrate bond pads on the substrate lower surface. The bond pads may be coupled to each other via metal layers in the substrate, vias, or any other number of electrical connections.

[0023] FIG. 4 illustrates a section view of the substrate 102 through the channel 202. The substrate 102 will be described from the bottom up. On a bottom of the substrate 102 is the substrate lower surface 400. The substrate lower surface 400 may be formed as part of a lower solder mask layer 402. Above the lower solder mask layer 402 is a first of a plurality of metal layers 404. The metal layers 404 may be disposed as shown, including lining a top and bottom of the channel 202. The metal layers 404 around the channel 202 may form structural components to stiffen the substrate 102. The other metal layers 404 may be used for electrical connections. The metal layers 404 may comprise one or more materials. Above the lower-most metal layer 404 is a first of a plurality of core layers 406. The core layers 406 may be non-conductive. Above the upper-most metal layer 404 (e.g., a signal layer), is an upper solder mask layer 408 that forms the substrate upper surface 200.

[0024] The transducer bond pads 302 and the ASIC die bond pads 304 may be portions of the upper-most metal layer 404 exposed via the upper solder mask layer 408. The substrate bond pads may be portions of the lower-most metal layer 404 exposed via the lower solder mask layer 402. Various vias, plugs, drills, pads, wires, and other structures through or on the substrate 102 may exist to facilitate signals/communications between the ASIC die 206 and the transducer 208 and/or between the ASIC die 206 and an external device.

[0025] FIG. 5 illustrates a bottom plan view of the substrate 102. The substrate 102 has a substrate lower surface 500 and substrate pins 502 that form a land grid array (LGA). The substrate pins 502 may be exposed portions of the lower-most metal layer 404 through the lower solder mask layer 402. The substrate pins 502 may enable communication between the ASIC die 206 and an external device and/or provide structural bonding between the substrate 102 (and thus, the differential pressure sensor 100) and the external device. The configuration of the substrate pins 502 may vary without departing from the scope of this disclosure. For example, there may be any number of substrate pins 502 and each substrate pin 502 may have any shape, size, and orientation.

[0026] FIG. 6 illustrates a top plan view of the differential pressure sensor 100 after the overmolding 104 has been applied to the substrate upper surface 200. After the overmolding 104 has been applied/formed, the differential pressure sensor 100 has the overmolding upper surface 210 with the first cavity 212 and the second cavity 214 formed within the overmolding 104 and exposing portions of the substrate upper surface 200. As discussed above, the first cavity 212 exposes the first port hole 300 and the transducer bond pads 302. The second cavity 214 exposes the second port hole 204. The overmolding 104 also encapsulates/covers the ASIC die 206.

[0027] FIG. 7 illustrates a top plan view of the differential pressure sensor 100 after an adhesive layer 700 has been applied to the substrate 102. The adhesive layer 700 is

configured to provide for pressure transfer between the channel **202** and an underside of the transducer **208** (e.g., a membrane of the transducer **208**), form a seal between the substrate upper surface and the underside of the transducer **208**, and also to provide stress decoupling (e.g., due to differences in thermal expansions) between the transducer **208** and the substrate **102**. The adhesive layer **700** surrounds the first port hole **300** and has a shape that corresponds to a perimeter of the transducer **208**. The adhesive layer **700** may be a low-modulus epoxy (e.g., 0.5 MPa at 100% elongation) and have a bond line thickness (BLT) of around 40 μm .

[0028] FIG. 8 illustrates a top plan view of the differential pressure sensor **100** after the transducer **208** is affixed to the substrate **102** via the adhesive layer **700**. The transducer **208** is affixed such that it covers the first port hole **300**. The transducer **208** includes transducer connection pads **800** that are configured to connect with the transducer bond pads **302**. In some implementations, the transducer **208** may be directly bonded to the transducer bond pads **302** and sealed using the adhesive layer **700**.

[0029] FIG. 9 illustrates a top plan view of the differential pressure sensor **100** after the transducer connection pads **800** are connected with the transducer bond pads **302**. The transducer connection pads **800** may be connected with the transducer bond pads **302** using wires **900**. Other ways of connecting the transducer connection pads **800** to the transducer bond pads **302** may be used without departing from the scope of this disclosure. For example, the transducer connection pads **800** may be connected with the transducer bond pads **302** as part of installing the transducer **208**. There may also be a connector to which the transducer **208** may be connected. Regardless, the connection of the transducer **208** ensures that the transducer **208** is in electrical connection with the ASIC die **206**.

[0030] FIG. 10 illustrates a top plan view of the differential pressure sensor **100** after the transducer **208** and associated connections have been covered with a protection layer **1000**. The protection layer **1000** is disposed within the first cavity **212** and configured to cover the transducer **208** and associated connections (e.g., the transducer connection pads **800**, the transducer bond pads **302**, the wires **900**). The protection layer **1000** is configured to adequately protect the components without affecting performance of the transducer **208**. For example, the protection layer **1000** may comprise a 100 μm thickness of a perfluoropolyether material (1-part or 2-part).

[0031] FIG. 11 illustrates a section view of the lid **106** through the first chimney **218** and the second chimney **220**. As discussed above, the lid **106** has a lid upper surface **216** and a lid lower surface **1100**. The first chimney **218** and the second chimney **220** extend from the lid upper surface **216** in a generally cylindrical manner. The first port **108** and the second port **110** are formed within the first chimney **218** and the second chimney **220**, respectively. Protruding from the lid lower surface **1100** are standoff **1102**. The standoffs **1102** are configured to maintain a separation distance between the lid **106** and the overmolding **104** when the lid **106** is attached to the overmolding **104** (e.g., to ensure a proper adhesive thickness). For example, the standoffs **1102** may be around 25 μm in height.

[0032] FIG. 12 illustrates a bottom plan view of the lid **106**. The first port **108** and the second port **110** run through the lid **106** to the lid lower surface **1100**. The standoffs **1102** may be placed in corners of the lid lower surface **1100** as

shown. A number and/or configuration of the standoffs **1102** may vary without departing from the scope of this disclosure. Furthermore, in some implementations, standoffs **1102** may not be used.

[0033] FIG. 13 illustrates an example method **1300** of manufacturing the differential pressure sensor **100**. Example method **1300** can include one or more operations, actions, or functions as illustrated by one or more of blocks **1302** to **1312**. Although illustrated as discrete blocks, various blocks may be divided into additional blocks, combined into fewer blocks, eliminated, performed in different order, or performed in parallel, depending on the desired implementation.

[0034] At **1302**, a substrate is provided. For example, the substrate **102** may be provided.

[0035] At **1304**, an ASIC die is mounted on the substrate. For example, the ASIC die **206** may be mounted on the substrate upper surface **200**. In some implementations, the ASIC die **206** may already be installed on the substrate **102** when it is provided, thus, rendering step **1304** moot.

[0036] At **1306**, an overmolding is formed on the substrate. For example, the overmolding **104** may be formed or molded on top of the substrate upper surface **200** forming the first cavity **212** and the second cavity **214**.

[0037] At **1308**, a transducer is mounted on the substrate. For example, the transducer **208** may be adhered to the substrate upper surface **200** via the adhesive layer **700**. The mounting may involve electrically connecting the transducer **208** to the substrate **102** (e.g., via wires **900**).

[0038] At **1310**, the transducer is sealed. For example, the protection layer **1000** may be applied within the first cavity **212**. The protection layer **1000** may cover the transducer **208** and associated wiring/connection points (e.g., the transducer connection pads **800**, the transducer bond pads **302**, and the wires **900**).

[0039] At **1312**, a lid is mounted on the overmolding. For example, the lid **106** may be attached to the overmolding upper surface **210**. The lid **106** may be attached using any mechanical or chemical means (e.g., a non-conductive epoxy) and may utilize standoffs **1102** to maintain a separation distance between the overmolding upper surface **210** and the lid lower surface **1100**.

[0040] The flowchart and block diagrams in the figures illustrate the architecture, functionality, and operation of possible implementations of systems, methods, and computer program products according to various embodiments of the present invention. In this regard, each block in the flowchart or block diagrams may represent a module, segment, or portion of instructions, which comprises one or more executable instructions for implementing the specified logical function(s). In some alternative implementations, the functions noted in the block may occur out of the order noted in the figures. For example, two blocks shown in succession may, in fact, be implemented substantially concurrently, or the blocks may sometimes be implemented in the reverse order, depending upon the functionality involved. It will also be noted that each block of the block diagrams and/or flowchart illustration, and combinations of blocks in the block diagrams and/or flowchart illustration, can be implemented by special purpose hardware-based systems that perform the specified functions or acts or carry out combinations of special purpose hardware and computer instructions.

[0041] The terminology used herein is for the purpose of describing particular embodiments only and is not intended to be limiting of the invention. As used herein, the singular forms “a”, “an” and “the” are intended to include the plural forms as well, unless the context clearly indicates otherwise. It will be further understood that the terms “comprises” and/or “comprising,” when used in this specification, specify the presence of stated features, integers, steps, operations, elements, and/or components, but do not preclude the presence or addition of one or more other features, integers, steps, operations, elements, components, and/or groups thereof.

[0042] The corresponding structures, materials, acts, and equivalents of all means or step plus function elements, if any, in the claims below are intended to include any structure, material, or act for performing the function in combination with other claimed elements as specifically claimed. The disclosed embodiments of the present invention have been presented for purposes of illustration and description but are not intended to be exhaustive or limited to the invention in the forms disclosed. Many modifications and variations will be apparent to those of ordinary skill in the art without departing from the scope and spirit of the invention. The embodiments were chosen and described in order to best explain the principles of the invention and the practical application, and to enable others of ordinary skill in the art to understand the invention for various embodiments with various modifications as are suited to the particular use contemplated.

What is claimed is:

1. A sensor device comprising:

a substrate:

- comprising a substrate upper surface;
- comprising a substrate lower surface opposite the substrate upper surface;
- forming a channel between the substrate upper surface and the substrate lower surface;
- forming a first port hole through the substrate upper surface to the channel; and
- forming a second port hole through the substrate upper surface to the channel;

an application-specific integrated circuit (ASIC) die mounted on the substrate upper surface so as not to cover the first port hole and the second port hole;

an overmolding:

- formed on the substrate upper surface;
- molded over the ASIC die;
- forming a first cavity surrounding the first port hole;
- forming a second cavity surrounding the second port hole; and
- comprising an overmolding upper surface;

a transducer:

- mounted on the substrate upper surface so as to cover the first port hole;
- placed within the first cavity; and
- electrically connected with the ASIC die; and

a lid:

- attached to the overmolding upper surface;
- comprising a lid upper surface;
- comprising a first chimney protruding from the lid upper surface and aligned with the first cavity; and
- comprising a second chimney protruding from the lid upper surface and aligned with the second cavity.

2. The sensor device of claim 1, wherein the sensor device is a differential pressure sensor.

3. The sensor device of claim 1, wherein the substrate further comprises a plurality of pins disposed on the substrate lower surface that are electrically connected with the ASIC die.

4. The sensor device of claim 1, wherein the channel has a rectangular cross section.

5. The sensor device of claim 1, wherein the channel is straight.

6. The sensor device of claim 1, wherein the channel has at least one dimension configured to mitigate condensation in the channel.

7. The sensor device of claim 1, wherein the ASIC die comprises a complementary metal oxide semiconductor (CMOS).

8. The sensor device of claim 1, wherein the transducer is a micro-electromechanical system (MEMS).

9. The sensor device of claim 1, wherein the transducer comprises a membrane.

10. The sensor device of claim 1, wherein the first chimney and the second chimney are configured to connect with tubing.

11. The sensor device of claim 1, wherein the first chimney and the second chimney are substantially cylindrical.

12. The sensor device of claim 1, wherein:

- the lid further comprises a lid lower surface opposite the lid upper surface; and
- the lid lower surface is attached to the overmolding upper surface.

13. The sensor device of claim 12, wherein the lid further comprises one or more standoffs configured to maintain a minimum adhesive thickness between the overmolding upper surface and the lid lower surface.

14. The sensor device of claim 1, wherein the lid is formed of a liquid-crystal polymer.

15. The sensor device of claim 1, wherein the sensor device further comprises a protection layer formed over the transducer.

16. The sensor device of claim 15, wherein the protection layer is configured to not affect performance of the transducer.

17. The sensor device of claim 1, wherein:

- the sensor device has a rectangular footprint; and
- the channel is formed diagonally across the rectangular footprint.

18. The sensor device of claim 1, wherein:

- the sensor device further comprises an adhesive layer disposed between the transducer and the substrate upper surface; and

the adhesive layer is configured to:

- allow for pressure transfer between the channel and an underside of the transducer;
- form a seal between the substrate upper surface and the underside of the transducer; and
- provide stress decoupling between the substrate upper surface and the transducer.

19. The sensor device of claim 1, wherein the substrate further comprises a plurality of pins disposed on the substrate lower surface that form a land grid array (LGA).

* * * * *